



Școala Doctorală de Chimie

TEMATICA PENTRU CONCURSUL DE ADMITERE LA DOCTORAT sesiunea iulie 2025

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1. Oxizi metalici obtinuti prin tehnica ALD (Atomic Layer Deposition) pentru producerea de hydrogen (ro)

Metal oxides obtained by ALD (Atomic Layer Deposition) technique for hydrogen production

Bibliografie/References

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